## **AMENDMENTS TO THE CLAIMS**

## Please add new claims 14-20 and amend the claims as follows:

1. (Currently Amended) A method of manufacturing porous glass base material for optical fiber, comprising:

flame-hydrolyzing raw materials in an oxyhydrogen flame to generate glass fine particles; using a burner to deposit depositing the glass fine particles on a rotating target to form said porous glass base material by using a burner, said burner being moved relatively to said rotating target;

moving said burner relative to said rotating target such that there is a moving area, on a surface of the rotating target, where the glass fine particles are carried in flame to directly hit the rotating target; and

adjusting an amount of hydrogen and oxygen supplied to said burner;

cooling a surface of the porous glass base material, during said using the burner to deposit the glass fine particles depositing, while adjusting a temperature difference (Ta-Tb) between a surface temperature of said porous glass base material when touching a flame of said burner moving area (Ta) and a surface temperature of an area of said porous glass base material prior to touching said flame of said burner outside said moving area (Tb) to be within a range from 200 °C to 700 °C; and

dehydrating and sintering said porous glass base material to transform said porous glass base material into clear glass.

2. (Currently Amended) A <u>porous</u> glass base material for optical fiber made of the <u>porous</u> glass base material obtained according to <u>the method of claim 1</u>, wherein said porous glass base material is dehydrated, sintered, and transformed into clear glass.

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3. (Currently Amended) The method of manufacturing porous glass base material for optical

fiber according to claim 1, wherein said rotating target moving area is displaced relative to as

said burner being moved moves.

4. (Currently Amended) The method of manufacturing porous glass base material for optical

fiber according to claim 1, wherein said burner comprises a concentric multi tube burner.

5. (Currently Amended) The method of manufacturing porous glass base material for optical

fiber according to claim 4, wherein said concentric multi tube burner comprises further

comprising:

supplying SiCl<sub>4</sub> and O<sub>2</sub> to a first tube supplied with SiCl<sub>4</sub> and O<sub>2</sub> of said concentric multi

tube burner during said depositing;

supplying air to a second tube supplied with air of said concentric multi tube burner

during said depositing;

supplying H<sub>2</sub> to a third tube supplied with H<sub>2</sub> of said concentric multi tube burner during

said depositing;

supplying N<sub>2</sub> to a fourth tube supplied with N<sub>2</sub> of said concentric multi tube burner during

said depositing; and

supplying O2 to a fifth tube supplied with O2 of said concentric multi tube burner during

said depositing.

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6. (Previously Presented) The method of manufacturing porous glass base material for

optical fiber according to claim 1, wherein said glass fine particles are deposited at a rate in a

range of 2040 g/hr to 2360 g/hr.

(Previously Presented) The method of manufacturing porous glass base material for 7.

optical fiber according to claim 1, wherein the temperature difference (Ta-Tb) is within a range

from 200 °C to 400°C.

8. (Withdrawn) The method of manufacturing porous glass base material for optical fiber

according to claim 1, wherein the temperature difference (Ta-Tb) is within a range from 500 °C

to 700 °C.

9. (Currently Amended) The method of manufacturing porous glass base material for

optical fiber according to claim 1, wherein a deposition efficiency was is in a range of 0.51 to

0.59.

10. (Withdrawn) The method of manufacturing porous glass base material for optical fiber

according to claim 1, wherein said glass fine particles are deposited at a rate in a range of 2040

g/hr to 2160 g/hr.

11. (Previously Presented) The method of manufacturing porous glass base material for

optical fiber according to claim 1, wherein said glass fine particles are deposited at a rate in a

range of 2200 g/hr to 2360 g/hr.

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12. (Currently Amended – Withdrawn) The method of manufacturing porous glass base material for optical fiber according to claim 1, wherein a deposition efficiency was <u>is</u> in a range of 0.51 to 0.54.

13. (Currently Amended) The method of manufacturing porous glass base material for optical fiber according to claim 1, wherein a deposition efficiency was is in a range of 0.55 to 0.59.

14. (New) A method of manufacturing glass base material for optical fiber, comprising:

the method of manufacturing porous glass base material according to claim 1; and
dehydrating and sintering said porous glass base material to transform said porous glass
base material into clear glass.

15. (New) The method of manufacturing porous glass base material for optical fiber according to claim 6, wherein the target has a diameter of about 50 mm when said depositing begins, and

wherein the porous glass base material has a diameter of about 300 mm when said depositing ends.

16. (New) The method of manufacturing porous glass base material for optical fiber according to claim 6, wherein said burner is one of four burners aligned at about 150 mm intervals.

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17. (New) The method of manufacturing porous glass base material for optical fiber

according to claim 11, wherein the target has a diameter of about 50 mm when said depositing

begins, and

wherein the porous glass base material has a diameter of about 300 mm when said

depositing ends.

18. (New) The method of manufacturing porous glass base material for optical fiber

according to claim 11, wherein said burner is one of four burners aligned at about 150 mm

intervals.

19. (New) The method of manufacturing porous glass base material for optical fiber

according to claim 9, wherein said burner comprises a concentric multi tube burner, the method

further comprising:

supplying SiCl<sub>4</sub> at about 1 Nl/min and O<sub>2</sub> at about 8 Nl/min to a first tube of said

concentric multi tube burner early in said depositing;

supplying SiCl<sub>4</sub> at about 10 Nl/min and O<sub>2</sub> at about 20 Nl/min to a first tube of said

concentric multi tube burner near the end of said depositing;

supplying air to a second tube of said concentric multi tube burner during said depositing;

supplying H<sub>2</sub> at about 50 NI/min to a third tube of said concentric multi tube burner early

in said depositing;

supplying H<sub>2</sub> at about 200 NI/min to a third tube of said concentric multi tube burner near

the end of said depositing;

supplying N2 at about 4 NI/min to a fourth tube of said concentric multi tube burner near

the end of said depositing;

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supplying O2 at about 20 NI/min to a fifth tube of said concentric multi tube burner early

in said depositing; and

supplying O2 at about 60 Nl/min to a fifth tube of said concentric multi tube burner near

the end of said depositing.

20. (New) The method of manufacturing porous glass base material for optical fiber

according to claim 13, wherein said burner comprises a concentric multi tube burner, the method

further comprising:

supplying SiCl<sub>4</sub> at about 1 Nl/min and O<sub>2</sub> at about 8 Nl/min to a first tube of said

concentric multi tube burner early in said depositing;

supplying SiCl<sub>4</sub> at about 10 Nl/min and O<sub>2</sub> at about 20 Nl/min to a first tube of said

concentric multi tube burner near the end of said depositing;

supplying air to a second tube of said concentric multi tube burner during said depositing;

supplying H<sub>2</sub> at about 50 NI/min to a third tube of said concentric multi tube burner early

in said depositing;

supplying H<sub>2</sub> at about 200 Nl/min to a third tube of said concentric multi tube burner near

the end of said depositing;

supplying  $N_2$  at about 4 NI/min to a fourth tube of said concentric multi tube burner near

the end of said depositing;

supplying O2 at about 20 NI/min to a fifth tube of said concentric multi tube burner early

in said depositing; and

supplying O2 at about 60 NI/min to a fifth tube of said concentric multi tube burner near

the end of said depositing.